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CATADIOPTIC IMAGING SYSTEM FOR BROAD BAND MICROSCOPY

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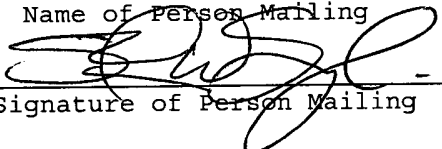
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CATADIOPTIC IMAGING SYSTEM FOR BROAD BAND MICROSCOPY

This application is a continuation-in-part of U.S. Patent Application Serial No. 10/434,374, entitled "High Performance Catadioptric Imaging System," inventors David G. Shafer, et al., filed May 7, 2003, which claims the benefit of U.S. Provisional Patent Application Serial No. 60/449,326, entitled "High Performance, Low Cost Catadioptric Imaging System," filed February 21, 2003.

10 BACKGROUND OF THE INVENTION

Field of the Invention

The present invention relates generally to the field of optical imaging, and more particularly to catadioptric optical systems used for microscopic imaging, inspection, and lithography applications.

Description of the Related Art

Many optical systems exist having the ability to inspect or image features on the surface of a specimen. Various applications employ microscopes for imaging purposes, including biology, metrology, semiconductor inspection, and other complex inspection applications wherein high resolution images of small areas and/or features are desired. Microscopes employ various imaging modes to enhance the appearance of desired features on the specimen. Imaging modes may include bright field, dark field, differential interference contrast, confocal, immersion, and others.

In many circumstances, a microscope capable of broad band imaging that also supports light energy in

the ultraviolet (UV) wavelength can be highly advantageous. One example of this type of imaging is called optical coherence tomography (OCT). OCT uses a broadband microscope to provide high resolution cross-sectional imaging of biological tissues. In an OCT design, the coherence length of the light employed governs the longitudinal resolution of the image, and light coherence length is inversely proportional to the bandwidth of the light. In an imaging design that performs broad band imaging and supports light energy in the UV wavelength range can provide improved lateral and longitudinal resolutions of the resultant image.

The imaging objective is one particular optical component that enables the microscope to perform broad band imaging while simultaneously supporting light wavelengths below 400nm. Certain UV objectives are capable of transmitting light down to a wavelength of 340nm, but these objectives do not provide accurate imaging performance for light wavelengths below 400nm. These types of objectives are mainly used for fluorescence, where wavelengths from 340nm through the visible light spectrum excite fluorescence components in marker dyes. Fluorescence type imaging is typically employed in the visible light spectrum, so imaging performance in the visible light spectrum is the specific type of performance required.

Few objectives are available that provide broad band performance at wavelengths below 400nm. Of the available objectives, none can be used in a standard

microscope system. They are either too large, have insufficient numerical aperture (NA), or have an insufficient field size.

With respect to NA, the NA of an objective
5 represents the objective's ability to collect light and resolve fine specimen detail at a fixed object distance. Numerical aperture is measured as the sine of the vertex angle of the largest cone of meridional rays that can enter or leave the optical system or
10 element, multiplied by the refractive index of the medium in which the vertex of the cone is located. A large numerical aperture provides distinct advantages during inspection, not the least of which is an ability to resolve smaller features of the specimen.
15 Also, high NAs collect a larger scattering angle, thereby improving performance in darkfield environments.

Two patents that disclose broad band, highly UV corrected, high numerical aperture (NA) catadioptric
20 systems are U.S. Patent 5,717,518 to Shafer et al. and U.S. Patent 6,483,638 to Shafer et al. A representative illustration of a catadioptric design
100 in accordance with the teachings of the '518 patent is presented in FIG. 1, which is similar to
25 FIG. 1 of the '518 patent. A representative illustration of a catadioptric design 200 in accordance with the teachings of the '638 patent is presented in FIG. 2, which has similarities to FIG. 4 of the '638 patent.

U.S. Patent 5,717,518 to Shafer et al. discloses an imaging design capable of high NA, ultra broadband UV imaging. The high NA (up to approximately 0.9) system can be used for broadband bright field and multiple wavelength dark-field imaging. Certain issues exist with designs similar to that presented in FIG. 1. First, the field lens group may need to be physically located within a central hole in the large curved catadioptric element, which can make manufacturing difficult and expensive. Second, the field lens elements in such a design may require at least one glued interface. In the presence of wavelengths less than 365nm, reliable glues that can withstand light intensity levels at an internal focus are generally unavailable. Third, the lens elements in such a design may be located very close to a field plane, thereby requiring a high degree of, or nearly perfect, surface quality and bulk material quality to prevent image degradation. Fourth, element diameters are typically larger than a standard microscope objective, especially for the catadioptric group. Large diameter elements frequently make integration into an inspection system difficult and can increase manufacturing costs.

The design of FIG. 2 is generally capable of high NA, ultra broadband UV imaging. The design is a high NA (up to approximately 0.9) imaging system that can be used for broadband bright field and multiple wavelength dark-field imaging and can use a varifocal tube lens to provide a large range of magnifications.

The FIG. 2 design introduces very tight tolerances in the field lens group, due in part to increased on-axis spherical aberration produced by the catadioptric group. This on-axis spherical aberration must be
 5 corrected by the following refractive lens elements. The design of FIG. 2 is relatively large, thereby generally requiring complicated optomechanical mounting of elements, especially in the catadioptric group.

10 With regard to the high NA designs of FIG. 1 and FIG. 2, microscopes place several significant constraints on the objectives employed. Distance from the specimen to the mounting flange is typically in the range of 45mm, while most objective turrets limit
 15 the objective diameter to 40mm. Threads used to screw the objective into the microscope turret are typically either 20mm, 25mm, or 32mm. Many microscope objectives employ all refractive design approaches, where all components are refractive elements. If an
 20 all refractive design is employed, the wavelength range used is limited by the available glass materials.

Other optical arrangements have been developed to perform specimen inspection in the microscopy field,
 25 but each arrangement tends to have certain specific drawbacks and limitations. Generally, in a high precision inspection environment, an objective with a short central wavelength provides advantages over those with long central wavelengths. Shorter
 30 wavelengths can enable higher optical resolution and

improved defect detection, and can facilitate improved defect isolation on upper layers of multi-layer specimens, such as semiconductor wafers. Shorter wavelengths can provide improved defect

5 characterization. An objective that can cover as large a wavelength range as possible may also be desirable, particularly when using an arc lamp as an illumination source. An all refractive objective design is difficult in this wavelength range because

10 few glass materials having high transmission are effective for chromatic correction. A small bandwidth may not be desirable for inspection applications due to limitation of available light power and increased interference from thin films on the surface being

15 inspected.

Small objectives are also desirable, as small objectives can be used in combination with standard microscope objectives and physically fit within standard microscope turrets. The standard objective

20 flange-to-object distance is in the range of 45mm. The available catadioptric objectives frequently cannot satisfy this requirement, so special microscope systems can be employed having an objective flange-to-object distance in excess of 60 mm and having lens

25 diameters greater than 60 mm. Certain of these smaller objectives have NAs limited to 0.75 and field sizes limited to 0.12mm with a bandwidth less than 10nm. Such designs typically use a Schwartzchild approach with lenses added within the catadioptric

30 group in an effort to improve performance. Working

distances are typically greater than 8 mm. Using a shorter working distance with this type of design approach can somewhat reduce the objective diameter at the cost of increasing central obscuration,
 5 significantly degrading objective performance.

An objective having low intrinsic aberrations is also desirable, as is an objective that is largely self-corrected for both monochromatic and chromatic aberrations. A self corrected objective will have
 10 looser alignment tolerances with other self corrected imaging optics. An objective with loose manufacturing tolerances, such as lens centering tolerances, may be particularly beneficial. Further, reducing incidence angles on lens surfaces can have a large effect on
 15 optical coating performance and manufacturing. In general, lower angles of incidence on lens surfaces also produce looser manufacturing tolerances.

It would be beneficial to provide a system for use in microscopy that overcomes the foregoing
 20 drawbacks present in previously known systems and provide an optical inspection system design having improved functionality over devices exhibiting those negative aspects described herein.

SUMMARY OF THE INVENTION

According to a first aspect of the present design, there is provided an objective employed for use with light energy having a wavelength in a range of approximately 266 to 1000 nanometers. The objective comprises a focusing lens group comprising at least one focusing lens configured to receive said light energy and form focused light energy, a field lens oriented to receive focused light energy from said focusing lens group and provide intermediate light energy, and a Mangin mirror arrangement positioned to receive the intermediate light energy from the field lens and form controlled light energy. Each focusing lens has a diameter of less than approximately 100 millimeters and a maximum corrected field size of approximately 0.15mm.

According to a second aspect of the present design, there is provided an objective employed for use with light energy having a wavelength in the range of approximately 157 nanometers through the infrared light range. The objective comprises a focusing lens group configured to receive said light energy and comprising at least one focusing lens, wherein each focusing lens in the focusing lens group has diameter less than approximately 100 millimeters, at least one field lens oriented to receive focused light energy from said focusing lens group and provide intermediate light energy, each field lens having diameter less than approximately 100 millimeters, and a Mangin mirror arrangement positioned to receive the

intermediate light energy from the field lens and form
controlled light energy, said Mangin mirror
arrangement imparting the controlled light energy to a
specimen with a numerical aperture in excess of 0.65
5 and a field size of approximately 0.15mm.

According to a third aspect of the present
design, there is provided an objective constructed of
a single glass material for use with light energy
having a wavelength in the range of approximately 157
10 nanometers through the infrared light range. The
objective comprises at least one focusing lens having
diameter less than approximately 100 millimeters
receiving said light energy and transmitting focused
light energy, at least one field lens having diameter
15 less than approximately 100 millimeters, receiving
said focused light energy and transmitting
intermediate light energy, and at least one Mangin
mirror element having diameter less than 100
millimeters receiving said intermediate light energy
20 and providing controlled light energy through an
immersion substance to a specimen.

According to a fourth aspect of the present
design, there is provided an objective constructed of
a single glass material for use with light energy
25 having a wavelength in the range of approximately 157
nanometers through the infrared light range. The
objective comprises at least one focusing lens having
diameter less than approximately 100 millimeters
receiving said light energy and transmitting focused
30 light energy, at least one field lens having diameter

less than approximately 100 millimeters, receiving
said focused light energy and transmitting
intermediate light energy, and at least one Mangin
mirror element having diameter less than 100
5 millimeters receiving said intermediate light energy
and providing controlled light energy through an
immersion substance to a specimen.

According to a fifth aspect of the present
design, there is provided a method for inspecting a
10 specimen. The method comprises providing light energy
having a wavelength in the range of approximately 157
nanometers through the infrared light range, focusing
said light energy using at least one lens into focused
light energy, where each lens used in said focusing
15 has diameter less than approximately 100 millimeters,
receiving said focused light energy and converting
said focused light energy into intermediate light
energy, and receiving said intermediate light energy
and providing controlled light energy through an
20 immersion substance to a specimen.

These and other aspects of the present invention
will become apparent to those skilled in the art from
the following detailed description of the invention
and the accompanying drawings.

DESCRIPTION OF THE DRAWINGS

The present invention is illustrated by way of example, and not by way of limitation, in the figures of the accompanying drawings in which:

5 FIG. 1 illustrates an aspect of the catadioptric objective design similar to that presented in FIG. 1 of U.S. Patent 5,717,518;

FIG. 2 is an aspect of the catadioptric objective design similar to that presented in FIG. 4 of U.S.
10 Patent 6,483,638;

FIG. 3 presents a seven element reduced size catadioptric objective with a high NA in accordance with the present design;

FIG. 4 presents an eight element reduced size
15 catadioptric objective with a high NA in accordance with the present design, corrected over a bandwidth from 266 to 1000nm and having a field size of approximately 0.150mm;

FIG. 5 presents a nine element reduced size
20 catadioptric objective with a high NA in accordance with the present design, corrected over a bandwidth from 266 to 1000nm and having a field size of approximately 0.150mm;

FIG. 6 is a graph of relative bandwidths
25 supported by the present design;

FIG. 7 shows an alternative nine element design optimized for a different central wavelength from that presented in FIG. 5;

FIG. 8 presents a different catadioptric group or
5 Mangin mirror arrangement for use of an objective in the presence of an immersion substance, such as water, oil, or a silicone gel;

FIG. 9 illustrates a catadioptric objective design including an immersion fluid;

10 FIG. 10 is a catadioptric objective design including an immersion fluid wherein the catadioptric group is fashioned from a single, solid element;

FIG. 11 shows a catadioptric objective design including an immersion fluid wherein the catadioptric
15 group includes two sets of lens mirror cavities; and

FIG. 12 is an objective having seven elements corrected over a wavelength range from 320-1300nm using a single glass material, or in certain circumstances, more than one glass material to improve
20 performance.

DETAILED DESCRIPTION OF THE INVENTION

The present design presents a catadioptric objective corrected over a wavelength range from 266-1000nm using a single glass material, or in certain
5 circumstances, more than one glass material to improve performance. The objective employed herein may provide particular benefits in the microscopy field. One aspect of the objective design is shown in FIG. 3. The catadioptric objective as shown in FIG. 3 is
10 optimized for broad-band imaging in the UV and visible spectral region, namely approximately 0.266 to 1.000 micron wavelengths. The objective provides relatively high numerical apertures and large object fields. The inventive design presented uses the Schupmann
15 principle in combination with an Offner field lens to correct for axial color and first order lateral color. As shown in the aspect presented in FIG. 3, the field lens group 305 is slightly displaced from the intermediate image 309 to obtain enhanced performance.

20 From FIG. 3, the catadioptric group 312 or Mangin mirror arrangement includes a Mangin mirror element 307. Mangin mirror element 307 is a reflectively coated lens element. The catadioptric group 312 also includes and a concave spherical reflector 306, also a
25 reflectively coated lens element. Both elements in the catadioptric group 312 have central optical apertures where reflective material is absent. This allows light to pass from the object or specimen 310 through Mangin mirror element 307, reflect from the
30 second or inner surface of concave spherical reflector

306, onto the reflective surface of Mangin mirror element 307, and through concave spherical reflector 306 to form an intermediate image 309 after concave spherical reflector 306 and field lens group 305. The
 5 field lens group 305 may comprise one or more lenses, and in the aspect shown in FIG. 3, one field lens is employed in the field lens group 305.

The focusing lens group 311 uses multiple lens elements, in the aspect shown four lens elements 301,
 10 302, 303, and 304. All lenses in the focusing lens group 311 may be formed from a single type of material to collect the light from the field lens group 305 and the intermediate image 309.

The lens prescription for the aspect of the
 15 invention illustrated in FIG. 3 is presented in Table 1.

Table 1. Prescription for lenses for the design of FIG. 3

Surf	Radius	Thickness	Glass
OBJ	Infinity	Infinity	
1	Infinity	15.612	
STO	Infinity	-15.612	
3	21.214	2.500	FUSED SILICA
4	Infinity	6.866	
5	-10.633	1.500	FUSED SILICA
6	-36.469	2.334	
7	Infinity	0.100	
8	10.162	3.000	FUSED SILICA
9	Infinity	5.985	
10	4.481	2.750	FUSED SILICA
11	30.793	4.432	
12	-5.645	1.000	FUSED SILICA

13	-2.872	0.250	
14	16.802	2.593	FUSED SILICA
15	12.273	7.711	
16	Infinity	3.603	FUSED SILICA
17	-181.041	-3.603	MIRROR
18	Infinity	-7.711	
19	12.273	-2.593	FUSED SILICA
20	16.802	2.593	MIRROR
21	12.273	7.711	
22	Infinity	3.603	FUSED SILICA
23	-181.041	0.375	
IMA	Infinity		

As may be appreciated by one skilled in the art, the numbers in the leftmost column of Table 1 represent the surface number counting surfaces from the left of FIG. 3. For example, the left surface of lens 301 in the orientation presented in FIG. 3 (surface 3 in Table 1) has a radius of curvature of 21.214mm, a thickness of 2.5 mm, and the rightmost surface (surface 4) has a radius of curvature of infinity, and is 6.866 mm from the next surface. The material used is fused silica.

In the design presented in FIG. 3, the numerical aperture may approach or even exceed approximately 0.90. The design presented herein, including the aspect illustrated in FIG. 3, provides a maximum numerical aperture in all cases in excess of 0.65.

From FIG. 3, the focusing lens group 311 has the ability to receive light energy and transmit focused light energy. The field lens group 305 has the ability to receive the focused light energy and

provide intermediate light energy, and form intermediate image 309. The catadioptric group or Mangin mirror arrangement 312 receives the intermediate energy and provides controlled light energy to the specimen. Alternately, the reflected path originates at the specimen, and light reflected from the specimen is received by the catadioptric group or Mangin mirror arrangement 312 and forms and transmits reflected light energy. The field lens group 305 receives the reflected light energy and transmitting resultant light energy, and the focusing lens group receives resultant light energy and transmits focused resultant light energy. The entrance pupil 308 represents an image of the internal pupil located within the objective. An aperture or mask can be placed at this entrance pupil 308 to limit or modify the NA of the objective.

The design presented in FIG. 3 and Table 1 thus uses a single glass material, fused silica. Other materials may be employed, but it is noted that fused silica or any material used within the design may require low absorption over a wide range of wavelengths from 190 nm through the infrared wavelength. Use of fused silica can enable the design to be re-optimized for any center wavelength in this wavelength range. For example, the design can be optimized for use with lasers at 193, 198.5, 213, 244, 248, 257, 266, 308, 325, 351, 355, or 364nm. The design can also be optimally employed to cover lamp spectral bands from 190-202, 210-220, 230-254, 285-

320, and 365-546nm. In addition, if calcium fluoride is employed as the glass or lens material, the design can be employed with an excimer laser at 157 nm or excimer lamps at 157 or 177nm. Re-optimization
5 requires tuning or altering components within the abilities of those skilled in the art. Calcium fluoride lenses may also be employed in the field lens group to increase the bandwidth of the objective, a modification discussed generally in U.S. Patent
10 5,717,518.

The maximum diameter of an objective element is 26 millimeters, which is significantly smaller than objectives previously employed in this wavelength range. The small size of this objective is
15 particularly beneficial in view of the performance characteristics of the objective. The objective can be mounted in a standard microscope turret with an approximate 45mm flange-to-object separation. The objective supports a numerical aperture of
20 approximately 0.90, a field size of approximately 0.4mm, has a corrected bandwidth from approximately 285-313nm, and a polychromatic wavefront error of less than approximately 0.067 waves.

Field size in this arrangement represents the
25 size of the area on the specimen that can be imaged the system with minimum degradation in optical performance. Generally, larger field sizes are beneficial in many applications.

As is true with any optical design, certain tradeoffs may be made to improve performance characteristics depending on the desired application of the objective or optical design. It is possible, 5 for example, to sacrifice bandwidth, field size, numerical aperture, and/or objective size to enhance one of the aforementioned performance characteristics, depending on the application. For example, optimizing for lower or higher NAs is possible. Reducing the NA 10 can reduce the manufacturing tolerance and the outer diameter of the objective. Lower NA designs can provide larger field sizes and larger bandwidths. Lower NA designs with the same performance and less optical elements are also possible. Optimizing for 15 higher NAs is also possible. Optimizing the design for higher NAs would generally limit the field size or bandwidth and may require slightly increased diameter objective elements. The design of FIG. 3 has a field size of 0.150mm in diameter.

20 The design of FIG. 3 provides a relatively low intrinsic polychromatic wavefront aberration over the design bandwidth from approximately 266-1000nm. The low wavefront aberration provides increased manufacturing headroom, or ease of manufacture, while 25 enabling relatively high performance of the manufactured objective. The design is also self corrected. Self corrected in this context means that the objective does not require any additional optical components to correct aberrations in order to achieve 30 design specifications. The ability to self correct

can provide for simpler optical testing metrology and optical alignment to other self corrected imaging optics. Further correction of residual aberrations using additional imaging optics is also possible. This
5 can increase the optical specifications such as bandwidth or field size.

One advantage of the present design is relatively loose manufacturing tolerances. Specifically, the decenter tolerances of individual lenses are
10 relatively loose. Having loose decenter tolerances for individual lens elements tends to simplify the manufacturing requirements of the system. Any lens decenters encountered during manufacturing may cause on-axis coma, a phenomenon that can be difficult to
15 compensate without introducing other residual aberrations. Using the present design, it is possible to reduce the decenter sensitivity of the lens and mirror elements by carefully balancing the aberrations within the catadioptric group 312 and focusing lens
20 group 311. Total aberrations of the catadioptric group may be optimized using the design of FIG. 3 to balance the compensation required by the field lens group 305 and focusing lens group 311.

Regarding decenter sensitivity for the objective,
25 a 10 micron decenter, without any compensators, introduces less than approximately 0.27 waves of aberration in all elements. The catadioptric group 312 is particularly insensitive in that a 10 micron decenter of element 306 and 307 introduces less than
30 0.15 waves of error. In the design presented in FIG.

3, average tolerance is approximately 0.15 waves of error at approximately 313nm. Further balancing of tolerances on the elements in the catadioptric group 312 is also possible to enhance decenter sensitivity
5 performance.

Decenter tolerances tend to scale with the wavelength employed due to optical path errors introduced for small decenters being roughly linear with wavelength. For example, if a 10 micron decenter
10 introduces 0.2 waves of aberration at a 266nm wavelength, operation is equivalent to an approximate 0.0532 micron optical path error. A system operating at 365nm would only introduce 0.15 waves of aberration for the same decenter, providing a similar approximate
15 0.0532 micron optical path error.

The foregoing decenter tolerances tend to be looser than other catadioptric designs in similar environments, and tend to be looser than most standard refractive objective designs. The design of FIG. 3
20 also has relatively loose tolerances on the index of the glass material, largely due to use of a single material that does not rely on the index difference of two different glass materials to compensate for chromatic aberrations. Use of a single material also
25 makes the design relatively insensitive to temperature changes. Previous designs have used multiple glass materials with different index profiles for color correction. The result is the index profile for each material changing differently with temperature,
30 thereby changing the chromatic correction for

temperatures other than the design temperature and reduced overall performance.

The objective design presented herein can support various modes of illumination and imaging. Modes supported can include bright field and a variety of dark field illumination and imaging modes. Other modes such as confocal, differential interference contrast, polarization contrast may also be supported using the present design.

Bright field mode is commonly used in microscope systems. The advantage of bright field illumination is the clarity of the image produced. Using bright field illumination with an objective such as that presented herein provides a relatively accurate representation of object feature size multiplied by the magnification of the optical system. The objective and optical components presented herein can be readily used with image comparison and processing algorithms for computerized object detection and classification.

Bright field mode typically uses a broad band incoherent light source, but it may be possible to use laser illumination sources with slightly modified illumination system components and employing the design presented herein.

The confocal mode has been used for optical sectioning to resolve height differences of object features. Most imaging modes have difficulty detecting changes in the height of features. The confocal mode forms separate images of object features at each height

of interest. Comparison of the images then shows the relative heights of different features. Confocal mode may be employed using the design presented herein.

Dark field mode has been used to detect features on
 5 objects. The advantage of the dark field mode is that flat specular areas scatter very little light toward the detector, resulting in a dark image. Surface features or objects protruding above the object tend to scatter light toward the detector. Thus, in inspecting objects
 10 like semiconductor wafers, dark field imaging produces an image of features, particles, or other irregularities on a dark background. The present design may be employed with dark field mode illumination. Dark field mode provides a large resultant signal upon striking
 15 small features that scatter light. This large resultant signal allows larger pixels to be employed for a given feature size, permitting faster object inspections. Fourier filtering can also be used to minimize the repeating pattern signal and enhance the defect signal
 20 to noise ratio during dark field inspection.

Many different dark field modes exist, each including a specific illumination and collection scheme. Illumination and collection schemes can be chosen such that the scattered and diffracted light collected from
 25 the object provides an acceptable signal-to-noise ratio. Certain optical systems use different dark field imaging modes including ring dark field, laser directional dark field, double dark field, and central dark ground. Each of these dark field imaging modes may be employed in the
 30 present design.

An alternate aspect of the present design presents an objective with eight separate elements. This aspect of the design is presented in FIG. 4. One difference between the design of FIG. 4 and that of
5 FIG. 3 is the addition of an extra element in contrast to reduced design tolerances. The objective of the design of FIG. 4 is corrected over a bandwidth from approximately 266 to 1000nm has a field size of approximately 0.150mm. The design of FIG. 4 maintains
10 the high approximately 0.90 numerical aperture. The worst case polychromatic wavefront error for the FIG. 4 design is approximately 0.062 waves.

From FIG. 4, the catadioptric group 413 includes a Mangin mirror element 408, which is a reflectively
15 coated lens element, and a concave spherical reflector 407, which is also a reflectively coated lens element. Both Mangin mirror element 408 and concave spherical reflector 407 have central optical apertures where reflective material is absent. The absence of
20 reflective material, in the center of the components shown, allows light to pass from the object or specimen 411 through Mangin mirror element 408, reflect from the second surface of concave spherical reflector 407 onto the Mangin mirror element 408, and
25 transmit through concave spherical reflector 407 to form an intermediate image 410 after concave spherical reflector 407 and field lens group 406, comprising a single field lens in this aspect of the design.

The focusing lens group 412 employs multiple lens
30 elements, in this aspect the five lens elements 401,

402, 403, 404, and 405, which may all be formed from a single type of material. The focusing lens group 412 collects light from the field lens group 406, including the intermediate image 410. The entrance pupil 409 is the image of the internal pupil within the objective. An aperture or mask can be placed at this entrance pupil 409 to limit or modify the NA of the objective. The design presented in FIG. 4 has the advantages and flexibility described with respect to the design of FIG. 3. The lens prescription for this embodiment is shown in Table 2.

Table 2. Prescription for lenses for the design of FIG. 4

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	Infinity		0.0
1	Infinity	18.442		10.5
STO	Infinity	-18.442		10.0
3	61.412	2.500	FUSED SILICA	10.5
4	-26.873	8.264		10.4
5	-7.688	1.500	FUSED SILICA	8.1
6	-49.641	2.881		8.6
7	Infinity	0.220		9.2
8	10.794	2.500	FUSED SILICA	9.5
9	74.618	0.100		9.2
10	7.061	2.750	FUSED SILICA	9.0
11	22.966	0.250		8.1
12	6.520	7.180	FUSED SILICA	7.4
13	-11.605	1.484		2.0
14	-5.176	1.000	FUSED SILICA	1.3
15	-2.511	0.250		2.2
16	17.165	2.500	FUSED SILICA	26.0
17	13.434	7.418		22.5

18	-281.019	3.829	FUSED SILICA	22.0
19	-122.544	-3.829	MIRROR	22.0
20	-281.019	-7.418		22.0
21	13.434	-2.500	FUSED SILICA	22.5
22	17.165	2.500	MIRROR	26.0
23	13.434	7.418		22.5
24	-281.019	3.829	FUSED SILICA	22.0
25	-122.544	0.375		22.0
IMA	Infinity			0.2

In this design, a 10 micron decenter, without compensators, introduces less than approximately 0.23 waves of aberration in all elements. The catadioptric group 413 is particularly insensitive with a 10 micron decenter of elements 407 and 408 introduces less than 0.15 waves of error. In the design presented in FIG. 3, average tolerance is approximately 0.15 waves of error at approximately 313nm.

10 An alternate aspect of the present design presents an objective with nine elements. This aspect of the design is presented in FIG. 5. The main difference between the design of FIG. 5 and that of FIG. 3 is the addition of two elements and reduced design tolerances. The objective of the design of FIG. 5 is corrected over a bandwidth from 266 to 1000nm and has a field size of approximately 0.150mm. The design of FIG. 5 maintains the high approximately 0.90 numerical aperture. The worst case polychromatic wavefront error for the FIG. 5 design is approximately 0.056 waves.

From FIG. 5, the catadioptric group 514 includes a Mangin mirror element 509, again a reflectively coated lens element, and a concave spherical reflector 508, which is also a reflectively coated lens element. Both Mangin mirror element 509 and concave spherical reflector 508 have central optical apertures where reflective material is absent. The absence of reflective material, in the center of the components shown, allows light to pass from the object or specimen 512 through Mangin mirror element 509, reflect from the second surface of concave spherical reflector 508 onto the Mangin mirror element 509, and transmit through concave spherical reflector 508 to form an intermediate image 511 after concave spherical reflector 508 and field lens group 507, comprising a single field lens in this aspect of the design.

The focusing lens group 513 employs multiple lens elements, in this aspect the six lens elements 501, 502, 503, 504, 505, and 506, which may all be formed from a single type of material. The focusing lens group 513 collects light from the field lens group 507, including the intermediate image 511. The entrance pupil 510 is the image of the internal pupil within the objective. An aperture or mask can be placed at this entrance pupil 510 to limit or modify the NA of the objective. The design presented in FIG. 5 has the advantages and flexibility described with respect to the design of FIG. 3. The lens prescription for this embodiment is shown in Table 3.

Table 3. Prescription for lenses for the design of
FIG. 5

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	Infinity		0.0
1	Infinity	17.404		9.1
STO	Infinity	-17.404		8.5
3	22.472	2.000	FUSED SILICA	9.0
4	-30.197	0.500		8.9
5	18.198	1.250	FUSED SILICA	8.4
6	6.908	5.699		7.6
7	-6.044	2.144	FUSED SILICA	7.6
8	-11.736	0.500		8.9
9	29.226	2.000	FUSED SILICA	9.4
10	-22.533	0.500		9.6
11	54.321	2.000	FUSED SILICA	9.5
12	-38.410	0.500		9.4
13	6.850	2.250	FUSED SILICA	8.9
14	20.279	7.835		8.2
15	2.040	1.249	FUSED SILICA	2.6
16	7.791	0.837		1.7
17	Infinity	1.000		0.6
18	17.766	3.020	FUSED SILICA	25.0
19	13.292	6.170		21.0
20	Infinity	4.900	FUSED SILICA	20.5
21	-76.135	-4.900	MIRROR	20.5
22	Infinity	-6.170		20.5
23	13.292	-3.020	FUSED SILICA	21.0
24	17.766	3.020	MIRROR	25.0
25	13.292	6.170		21.0
26	Infinity	4.900	FUSED SILICA	20.5
27	-76.135	0.300		20.5
IMA	Infinity			0.2

For the objective of FIG. 5, a 10 micron decenter,
5 without using any compensators, introduces less than
approximately 0.25 waves of aberration in all
elements. Average tolerance is approximately 0.13
waves of error at approximately 313nm.

The present small catadioptric objective design approach allows for very wide corrected bandwidths using a single glass material and maintains smaller lens diameters than previously employed. Past designs
5 have had field sizes of in the range of approximately 0.4mm with relative bandwidths limited to a range of approximately 0.19 for a fully self corrected objective. These new designs have smaller field sizes of approximately 0.15mm and larger relative bandwidths
10 up to approximately 0.9 for a fully self corrected objective.

Relative bandwidths supported by the designs in FIG 3, FIG 4, and FIG 5 are shown FIG. 6. In this context, the relative bandwidth represents the ratio
15 of the bandwidth divided by the central wavelength. The relatively large relative bandwidths available in the present design extend into the UV wavelengths below 400nm. Generally, a higher relative bandwidth is preferred in many scenarios, as colors tend to
20 appear more robust. In addition, relative bandwidth tends to decrease as central wavelength decreases due to the index of refraction for the material increasing in a nonlinear fashion. This phenomenon complicates producing an objective with a short central wavelength
25 and a high relative bandwidth, in many cases making objective production virtually impossible. The higher performance and large relative bandwidths provided by the present design, as illustrated in FIG. 6 are highly desirable.

Another aspect of the design presents an objective having nine elements. This aspect of the design is presented in FIG. 7. One difference between the design of FIG. 7 and that of FIG. 5 is

5 optimization for a different central wavelength. The objective of the design of FIG. 7 is corrected over a bandwidth from 190 to 202nm has a field size of approximately 0.150mm. For this objective, relative bandwidth is approximately 0.06, a value much broader

10 than typical catadioptric designs with a central wavelength of 196nm. Previous designs have demonstrated relative bandwidths less than approximately 0.005 at 196nm. The design of FIG. 7 again provides a relatively high approximately 0.90

15 numerical aperture. Worst case polychromatic wavefront error for the FIG. 7 design is approximately 0.045 waves.

From FIG. 7, the catadioptric group 714 includes a Mangin mirror element 709, which is a reflectively

20 coated lens element, and a concave spherical reflector 708, which is also a reflectively coated lens element. Both Mangin mirror element 709 and concave spherical reflector 708 have central optical apertures where reflective material is absent. The absence of

25 reflective material, in the center of these components allows light to pass from the object or specimen 712 through Mangin mirror element 709, reflect from the second surface of concave spherical reflector 708 onto the Mangin mirror element 709, and transmit through

30 concave spherical reflector 708 to form an

intermediate image 711 after concave spherical reflector 708 and field lens group 707. Field lens group 707 comprises a single field lens in this aspect of the design.

5 The focusing lens group 713 employs multiple lens elements, in this aspect the six lens elements 701, 702, 703, 704, 705, and 706, which may all be formed from a single type of material. The focusing lens group 713 collects light from the field lens group
10 707, including the intermediate image 711. The entrance pupil 710 is the image of the internal pupil within the objective. An aperture or mask can be placed at this entrance pupil 710 to limit or modify the NA of the objective.

15 The lens prescription for this embodiment is shown in Table 4.

Table 4. Prescription for lenses for the design of FIG. 7

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	Infinity		0.0
1	Infinity	16.374		9.0
STO	Infinity	-16.374		8.5
3	13.996	2.500	FUSED SILICA	9.0
4	-44.912	0.500		8.6
5	70.761	1.250	FUSED SILICA	8.2
6	6.483	4.999		7.3
7	-4.675	1.964	FUSED SILICA	7.6
8	-5.735	0.500		9.1
9	15.538	2.500	FUSED SILICA	9.9
10	-48.225	0.500		9.7
11	8.447	2.250	FUSED SILICA	9.2
12	22.024	1.498		8.4
13	Infinity	1.500		7.6

14	-12.098	3.323	FUSED SILICA	6.9
15	-10.131	3.985		6.2
16	2.582	1.250	FUSED SILICA	2.8
17	11.533	1.216		2.0
18	Infinity	0.699		0.4
19	17.897	3.038	FUSED SILICA	25.0
20	13.385	6.122		21.0
21	Infinity	5.409	FUSED SILICA	20.5
22	-73.634	-5.409	MIRROR	20.5
23	Infinity	-6.122		20.5
24	13.385	-3.038	FUSED SILICA	21.0
25	17.897	3.038	MIRROR	25.0
26	13.385	6.122		21.0
27	Infinity	5.409	FUSED SILICA	20.5
28	-73.634	0.300		20.5
IMA	Infinity			0.2

Another aspect of the present design includes an objective capable of immersion imaging. Immersion is used for achieving high NAs for increased resolution.

5 Placing a fluid between the sample or specimen and the objective provides a design having increased NA. If the space between the sample and the objective has an oil with an index of 1.5 and a 64 degree marginal ray angle, the resultant NA will be approximately 1.35.

10 Employing immersion in the design of FIG. 3 entails placing fluid between the Mangin element 307, which has two surfaces with flat to mild curvatures and specimen 310 so that the NA is greater than one in that region. Any light reaching the second surface or
15 rightmost surface of Mangin element 307 with an angle of greater than 41 degrees will be totally internally reflected.

The design of FIG. 8 addresses the immersion in the presence of curved elements issue by increasing the curvature of the second surface of the Mangin element 802 nearest the specimen 801. The revised
5 thicknesses and curvatures of elements 802 and 803 provide a Mangin mirror arrangement or catadioptric group having the ability to operate in the presence of immersion. The design of the catadioptric group corrects spherical aberration along with axial color
10 and the chromatic variation of spherical aberration. Deviations from this catadioptric form can produce compensating aberrations for any subsequent or following refractive elements.

One such immersion design based on this
15 catadioptric design is shown in FIG. 9. The objective of the design of FIG. 9 is corrected over a bandwidth from approximately 266 to 436nm and has a field size of approximately 0.150mm. The design of FIG. 9 maintains the relatively high approximately 1.1
20 numerical aperture. The worst case polychromatic wavefront error for the FIG. 9 design is approximately 0.057 waves.

From FIG. 9, the catadioptric group 918 includes a Mangin mirror element 912, which is a reflectively
25 coated lens element, and a concave spherical reflector 911, which is also a reflectively coated lens element. Both Mangin mirror element 912 and concave spherical reflector 911 have central optical apertures where reflective material is absent. The absence of
30 reflective material from the center of the components

shown allows light to pass from the object or specimen
 913 through Mangin mirror element 912, reflect from
 the second surface of concave spherical reflector 911
 onto the Mangin mirror element 912, and transmit
 5 through concave spherical reflector 911 to form an
 intermediate image 915 after passing concave spherical
 reflector 911 and field lens group 917, comprising
 lenses 908, 909, and 910 in this aspect of the design.

The focusing lens group 916 employs multiple lens
 10 elements, in this aspect the seven lens elements 901,
 902, 903, 904, 905, 906, and 907. The focusing lens
 group 916 collects light from the field lens group
 917, including the intermediate image 915. The
 entrance pupil 914 is the image of the internal pupil
 15 within the objective. Again, an aperture or mask can
 be placed at this entrance pupil 914 to limit or
 modify the NA of the objective. The lens prescription
 for the design of FIG. 12 is shown in Table 5.

20 **Table 5. Prescription for lenses for the design of
 FIG. 12**

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	Infinity		0.0
1	Infinity	23.363		8.8
STO	Infinity	-23.363		7.8
3	17.529	1.500	CALCIUM FLUORIDE	8.8
4	123.317	6.560		8.6
5	8.254	1.750	CALCIUM FLUORIDE	6.9
6	-21.949	0.099		6.5
7	8.712	1.250	FUSED SILICA	5.8
8	3.105	0.684		4.5
9	5.063	2.089	CALCIUM FLUORIDE	4.4
10	-11.418	0.470		3.7
11	-4.096	5.352	FUSED SILICA	3.6

12	93.921	0.250		3.2
13	2.946	2.000	CALCIUM FLUORIDE	3.1
14	-3.475	0.249		2.5
15	-2.433	1.250	FUSED SILICA	2.3
16	3.487	0.231		1.8
17	2.262	2.250	CALCIUM FLUORIDE	1.8
18	-5.028	0.110		1.0
19	2.727	1.250	CALCIUM FLUORIDE	0.9
20	-1.967	0.243		1.1
21	-1.513	2.577	FUSED SILICA	1.2
22	2.241	0.608		2.1
23	19.760	3.499	FUSED SILICA	25.0
24	27.518	0.717		23.0
25	33.723	10.010	FUSED SILICA	23.0
26	Infinity	-10.010	MIRROR	23.0
27	33.723	-0.717		23.0
28	27.518	-3.499	FUSED SILICA	23.0
29	19.760	3.499	MIRROR	25.0
30	27.518	0.717		23.0
31	33.723	10.010	FUSED SILICA	23.0
32	Infinity	0.375	IMMERSION FLUID	23.0
IMA	Infinity			0.2

An additional aspect of the present design uses a different approach to address the immersion issue with a similar catadioptric objective design. The

5 catadioptric group may be fashioned from a single, solid element. A design based on this type of catadioptric group is shown in FIG. 10. The objective of the design of FIG. 10 is corrected over a bandwidth from 266 to 436nm and has a field size of 0.150mm.

10 The design of FIG. 10 maintains the high approximately 0.95 numerical aperture. A worst case polychromatic wavefront error for the FIG. 10 design is approximately 0.037 waves.

From FIG. 10, the catadioptric group 1014

15 includes a single Mangin mirror element 1002, which is

reflectively coated on both sides. Both sides of Mangin mirror element 1002 have central optical apertures where reflective material is absent. Again, as with previous design aspects, the absence of
5 reflective material from the center of the components shown allows light to pass from the object or specimen 1001 through the first surface of Mangin mirror element 1002, reflect from the second surface of element 1002 transmit to the first surface of Mangin
10 mirror element 1002. Light energy then reflects from the first surface of element 1002 and passes through the second surface of element 1002 to form an intermediate image 1013 after passing field lens group 1015, comprising lenses 1003 and 1004 in this aspect
15 of the design.

From FIG. 10, the space between specimen 1001 and Mangin mirror element 1002 is filled by the immersion substance or immersion fluid. Immersion fluid is therefore typically in direct contact with element
20 1002. Element 1002 may have a reflective coating on the right hand side with a small aperture in the center to allow light to pass through to the immersion fluid and to the specimen. In normal operation, a small amount of immersion substance, such as a drop of
25 immersion fluid, is placed on the object to be imaged, such as specimen 1001. The system brings the objective into relatively close proximity with the specimen 1001. When the objective touches the immersion fluid, the immersion fluid expands to fill
30 the gap between element 1002 and the specimen 1001.

The focusing lens group 1016 employs multiple lens elements, in this aspect the eight lens elements 1005, 1006, 1007, 1008, 1009, 1010, 1011, and 1012. The focusing lens group 1016 collects light from the
 5 field lens group 1015, including the intermediate image 1013.

The lens prescription for the design of FIG. 10 is shown in Table 6.

10 **Table 6. Prescription for lenses for the design of FIG. 10**

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	0.375	IMMERSION FLUID	0.0
1	Infinity	13.250	FUSED SILICA	18.0
STO	-18.906	-13.250	MIRROR	18.0
3	Infinity	13.250	MIRROR	18.0
4	-18.906	0.313		18.0
5	-2.281	1.514	FUSED SILICA	1.7
6	2.442	0.292		1.2
7	18.937	2.015	CALCIUM FLUORIDE	1.1
8	-2.371	3.750		0.8
9	3.981	2.250	CALCIUM FLUORIDE	1.3
10	-2.017	0.125		1.7
11	-1.975	1.250	FUSED SILICA	1.7
12	2.762	0.250		2.0
13	3.800	2.500	CALCIUM FLUORIDE	2.2
14	-3.788	0.250		2.8
15	27.780	1.356	FUSED SILICA	2.8
16	7.300	0.250		2.9
17	7.757	4.063	CALCIUM FLUORIDE	2.9
18	-3.391	0.250		3.1
19	-3.101	1.250	FUSED SILICA	3.0
20	3.484	0.500		3.2

21	7.930	1.750	CALCIUM FLUORIDE	3.4
22	-9.660	5.199		3.8
23	24.789	2.250	CALCIUM FLUORIDE	5.7
24	-13.120	5.000		6.0
25	-	11.336		6.0
IMA	Infinity			0.9

Another approach to operating in the presence of immersion fluid operates with the catadioptric group including two sets of lens mirror cavities. A design
5 based on this type of catadioptric group is shown in FIG. 11. The objective of the design of FIG. 11 is corrected over a bandwidth from 266 to 320nm has a field size of 0.150mm. The design of FIG. 11 maintains the high approximately 1.15 numerical
10 aperture. Worst case polychromatic wavefront error for the FIG. 11 design is approximately 0.052 waves.

From FIG. 11, the catadioptric group 1113 includes a first Mangin mirror element 1102, reflectively coated on one side, mirror 1103,
15 reflectively coated on both sides, lens 1104, and second Mangin mirror element 1105, reflectively coated on the second side, or outer left hand side in the orientation shown. The front side of first Mangin mirror element 1102, both sides of mirror 1103, and
20 the second side of second Mangin mirror element 1105 have central optical apertures where reflective material is absent. The absence of reflective material, in the center of the components shown, allows light to pass from the object or specimen 1101
25 through the first surface of first Mangin mirror

element 1102, reflect from the first surface of
 element 1103 transmit to the first surface of first
 Mangin mirror element 1102, reflect from the first
 surface of first Mangin mirror element 1102 and
 5 transmit through the second surface of element 1103 to
 form a first intermediate image 1115. Light then
 passes through lens element 1104 and reflects off the
 second surface of second Mangin element 1105 before
 returning through lens 1104, reflecting off the second
 10 surface of mirror 1103, and forming second
 intermediate image 1116 after passing lens 1104,
 second Mangin element 1105, and field lens group
 comprising a single lens 1106 in this aspect of the
 design.

15 The space between specimen 1101 and first Mangin
 mirror element 1102 is filled by the immersion
 substance or immersion fluid. Immersion fluid is
 therefore typically in direct contact with element
 1102. First Mangin mirror element 1102 may have a
 20 reflective coating on the right hand side with a small
 aperture in the center to allow light to pass through
 to the immersion fluid and to the specimen 1101. In
 normal operation, a small amount of immersion
 substance, such as a drop of immersion fluid, is
 25 placed on the object to be imaged, such as specimen
 1101. The system brings the objective into relatively
 close proximity with the specimen 1101. When the
 objective touches the immersion fluid, the immersion
 fluid expands to fill the gap between first Mangin
 30 mirror element 1102 and the specimen 1001.

The focusing lens group 1114 employs multiple lens elements, in this aspect the six lens elements 1107, 1108, 1109, 1110, 1111, and 1112. The focusing lens group 1114 collects light from the field lens group 1106, including the intermediate image 1116.

The lens prescription for the design of FIG. 11 is shown in Table 7.

Table 7. Prescription for lenses for the design of FIG. 11

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	1.000	IMMERSION FLUID	0.030165
1	Infinity	-0.675	IMMERSION FLUID	20
2	Infinity	9.443	FUSED SILICA	20
3	-25.125	2.328		20
4	-14.436	-2.328	MIRROR	20
5	-25.125	-9.443	FUSED SILICA	20
6	Infinity	9.443	MIRROR	20
7	-25.125	2.328		20
8	-14.427	1.750	FUSED SILICA	20
9	29.875	5.071		16
10	-8.482	4.931	FUSED SILICA	13
11	-9.652	2.877		16
12	-41.988	2.500	FUSED SILICA	16
13	-32.709	-2.500	MIRROR	16
14	-41.988	-2.877		16
15	-9.652	-4.931	FUSED SILICA	16
16	-8.482	-5.071		13
STO	29.875	5.071	MIRROR	13
18	-8.482	4.931	FUSED SILICA	13
19	-9.652	2.877		16
20	-41.988	2.500	FUSED SILICA	16
21	-32.709	0.250		16
22	5.939	1.500	FUSED SILICA	3
23	-5.557	1.332		3
24	3.374	2.422	FUSED SILICA	3
25	5.773	0.336		3

26	4.071	1.500	FUSED SILICA	3.5
27	-3.249	0.250		3.5
28	2.358	1.500	FUSED SILICA	4
29	3.166	1.092		3
30	-2.132	1.250	FUSED SILICA	3
31	4.177	0.746		4
32	-32.009	1.500	FUSED SILICA	4.5
33	-4.559	0.100		5.5
34	8.802	2.000	FUSED SILICA	7
35	-12.695	4.750		7
36	-	10.000		4.942964
IMA	Infinity			0.166772

An alternate aspect of the present design presents an objective having seven elements corrected over a wavelength range from 320-1300nm using a single glass material, or in certain circumstances, more than one glass material to improve performance. One aspect of such an objective design is shown in FIG. 12. The catadioptric objective as shown in FIG. 12 is optimized for broad-band imaging in the UV through the infrared spectral region, namely approximately 0.320 to 1.3 micron wavelengths.

From FIG. 12, the catadioptric group 1212 or Mangin mirror arrangement includes a Mangin mirror element 1207. Mangin mirror element 1207 is a reflectively coated lens element. The catadioptric group 1212 also includes and a concave spherical reflector 1206, also a reflectively coated lens element. Both elements in the catadioptric group 1212 have central optical apertures where reflective material is absent. This allows light to pass from the object or specimen 1210 through Mangin mirror element

1207, reflect from the second or inner surface of concave spherical reflector 1206, onto the reflective surface of Mangin mirror element 1207, and through concave spherical reflector 1206 to form an

5 intermediate image 1209 after concave spherical reflector 1206 and field lens group 1205. The field lens group 1205 may comprise one or more lenses, and in the aspect shown in FIG. 12, one field lens is employed in the field lens group 1205.

10 The focusing lens group 1211 uses multiple lens elements, in the aspect shown four lens elements 1201, 1202, 1203, and 1204. All lenses in the focusing lens group 311 may be formed from a single type of material to collect the light from the field lens group 1205
15 and the intermediate image 1209. The entrance pupil 1208 is the image of the internal pupil within the objective. An aperture or mask can be placed at this entrance pupil 1208 to limit or modify the NA of the objective.

20 The lens prescription for the aspect of the invention illustrated in FIG. 12 is presented in Table 8.

Table 8. Prescription for lenses for the design of FIG. 12

Surf	Radius	Thickness	Glass	Diameter
OBJ	Infinity	Infinity		0.0
1	Infinity	15.612		12.4
STO	Infinity	-15.612		12.0
3	21.987	2.500	FUSED SILICA	12.3
4	Infinity	6.866		12.0

5	-10.614	1.500	FUSED SILICA	10.5
6	-37.828	1.900		10.9
7	Infinity	0.100		11.1
8	10.233	3.000	FUSED SILICA	11.3
9	Infinity	4.985		10.9
10	5.054	5.802	FUSED SILICA	7.8
11	Infinity	2.914		4.1
12	-7.057	1.500	FUSED SILICA	1.5
13	-2.981	0.250		2.7
14	16.091	1.967	FUSED SILICA	26.0
15	12.205	7.862		22.5
16	Infinity	3.479	FUSED SILICA	22.0
17	-231.641	-3.479	MIRROR	22.0
18	Infinity	-7.862		22.0
19	12.205	-1.967	FUSED SILICA	22.5
20	16.091	1.967	MIRROR	26.0
21	12.205	7.862		22.5
22	Infinity	3.479	FUSED SILICA	22.0
23	-231.641	0.375		22.0
IMA	Infinity			0.2

In the design presented in FIG. 12, the numerical aperture may approach or even exceed approximately 0.90. The design presented herein, including the aspect illustrated in FIG. 12, provides a maximum numerical aperture in all cases in excess of 0.65.

From FIG. 12, the focusing lens group 1211 has the ability to receive light energy and transmit focused light energy. The field lens group 1205 has the ability to receive the focused light energy and provide intermediate light energy, and form intermediate image 1209. The catadioptric group or Mangin mirror arrangement 1212 receives the intermediate energy and provides controlled light

energy to the specimen. Alternately, the reflected path originates at the specimen, and light reflected from the specimen is received by the catadioptric group or Mangin mirror arrangement 1212 and forms and
 5 transmits reflected light energy. The field lens group 1205 receives the reflected light energy and transmitting resultant light energy, and the focusing lens group receives resultant light energy and transmits focused resultant light energy.

10 The present system design may be employed in various environments, including but not limited to lithography, microscopy, biological inspection, medical research, and the like.

 The design presented herein and the specific
 15 aspects illustrated are meant not to be limiting, but may include alternate components while still incorporating the teachings and benefits of the invention, namely the small design having a high NA able to be employed in various wavelengths using
 20 different illumination modes. While the invention has thus been described in connection with specific embodiments thereof, it will be understood that the invention is capable of further modifications. This application is intended to cover any variations, uses
 25 or adaptations of the invention following, in general, the principles of the invention, and including such departures from the present disclosure as come within known and customary practice within the art to which the invention pertains.

While the invention has been described in connection with specific embodiments thereof, it will be understood that the invention is capable of further modifications. This application is intended to cover
5 any variations, uses or adaptations of the invention following, in general, the principles of the invention, and including such departures from the present disclosure as come within known and customary practice within the art to which the invention
10 pertains.